

ABSTRACT OF THE DISCLOSURE

The present invention provides a laminate for IR ablation comprising at least a substrate and an IR ablation layer,
5 wherein the aforementioned IR ablation layer comprises an IR absorbent metal layer and a method for forming a mask on a photosensitive resin layer, which comprises a step of IR ablation of a laminate comprising at least a substrate and an IR ablation layer which is laminated on said photosensitive
10 resin layer, wherein the IR ablation layer comprises an IR absorbent metal layer.